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(54) Title: NEGATIVE-WORKING LITHOGRAPHIC PRINTING PLATE PRECURSOR

(57) Abstract: A negative-working lithographic printing plate precursor has a substrate and an imageable layer disposed on the substrate. This imageable is removable with a lithographic printing ink, a fountain solution, or both. The imageable layer comprises (A) a free radical polymerizable compound, (B) a free radical polymerization initiator, and (C) a polymer that has a polysaccharide backbone and a free radical polymerizable group that is different than (A). Such precursors are on-press developable and exhibit excellent on-press development stability over time and excellent printing properties.